

Table S1. Chemical composition and preparation of the composites.

Code	Metal	Si to metal atomic ratio	Chemical form of metal	Preparation method	Reference
Al1	Al	Si/Al 95.0	Al ₂ O ₃	Mixed in one-pot Al ₂ O ₃	12
Al2		Si/Al 78.0			
Al3		Si/Al 54.0			
Al4		Si/Al 31.0			
Al5		Si/Al 22.0			
Al6		Si/Al 14.0			
Al7		Si/Al 56.0			
Al8		Si/Al 16.0			
Al9	Al	Si/Al 20.4	Chemical vapor deposition AlCl ₃ hydrolysis	13	
Al10		Si/Al 22.0			
Al11		Si/Al 4.2			
Al12		Si/Al 11.8			
Al13		Si/Al 13.1			
Al14		Si/Al 11.7			
Al15	Al	Si/Al 5.0	One-pot method Al ₂ (SO ₄) ₃	14	
Al16		Si/Al 10.0			
Al17		Si/Al 20.0			
Al18	Al	Si/Al 10.1	Hydrothermal active γ-Al ₂ O ₃ ground to 1 mm with a ball grinder	15	
Al19		Si/Al 5.4			
Al20		Si/Al 2.9			
Al21	Al	Si/Al 20.0	Sodium-aluminate	16	
Al/Ti1	Al Ti	Si/Al 8.4	Chemical vapor deposition AlCl ₃ TiCl ₄ hydrolysis	13	
Al/Ti2		Si/Ti 16.8			
		Si/Al 8.0			
		Si/Ti 14.6			

Ca1	Ca	Si/Ca 8.7		Wetness impregnation $\text{Ca}(\text{NO}_3)_2$	17
Ca2	Ca	Si/Ca 10.0		One-pot route $\text{Ca}(\text{NO}_3)_2$	18
Ca3		Si/Ca 5.0			
Ca4		Si/Ca 3.3			
Ca5		Si/Ca 2.5			
Ca6		Si/Ca 2.0			
Ca7		Si/Ca 2.5		Wetness impregnation $\text{Ca}(\text{NO}_3)_2$	
Cd1	Cd	Si/Cd 467.8	CdO	Chemical vapor deposition Cd (metal)	19
Cd2		Si/Cd 17.2			
Cd3		Si/Cd 28.3			
Cd4		Si/Cd 143.9			
Cd5		Si/Cd 46.8			
Cd6		Si/Cd 1871.0			
Cd7		Si/Cd 38.2			
Cd8		Si/Cd 42.5			
Cd9		Si/Cd 26.4			
Cd10		Si/Cd 27.9			
Cd11		Si/Cd 53.5			
Ce1	Ce	Si/Ce 32.2	CeO ₂	Hydrothermal $\text{Ce}(\text{NO}_3)_3$	20
Ce2	Ce	Si/Ce 21.0	CeO ₂	Wetness impregnation $\text{Ce}(\text{NO}_3)_2$	21
Ce3	Ce	Si/Ce 8.6	CeO ₂	$\text{Ce}(\text{NO}_3)_3$	22
Ce4		Si/Ce 16.2			
Ce5		Si/Ce 32.9			

Ce6	Ce	Si/Ce 36.5	CeO ₂	Wetness impregnation Ce(NO ₃) ₃	23
Ce7	Ce	Si/Ce 52.6		Hydrothermal Ce(NO ₃) ₃	24
Ce8		Si/Ce 26.3			
Ce9		Si/Ce 18.2			
Ce10		Si/Ce 13.2			
Ce11	Ce	Si/Ce 1000	-	Colloidal acidic suspension of CeO ₂ nanoparticles (10% in water)	25
Ce12		Si/Ce 100	CeO ₂		
Ce13		Si/Ce 33.3			
Ce14		Si/Ce 12.5			
Ce15	Ce	Si/Ce 31.0	CeO ₂	Wetness impregnation Ce(NO ₃) ₃	26
Ce/Ni8	Ni Ce	Si/Ce 100	CeO ₂	Colloidal acidic suspension of CeO ₂ nanoparticles (10% in water) Wetness impregnation Ni(NO ₃) ₂	25
Ce/Ni9		Si/Ni 18.6	Ni		
Ce/Ni10		Si/Ce 33.3			
Ce/Ni10		Si/Ni 18.6			
Ce/Ni11	Ce Ni	Si/Ce 117.0	Ni	surfactant-assisted iso-volumetric impregnation method Ni(NO ₃) ₃ Ce(NO ₃) ₃ cetyltrimethylammonium bromide (CTAB)	27
Ce/Ni12		Si/Ni 33.2			
Ce/Ni13		Si/Ce 62.5			
Ce/Ni14		Si/Ni 33.9			
Ce/Zr1	Ce Zr	Si/Ce 29.6	CeO ₂	Wetness impregnation	26
		Si/Ni 31.4			
		Si/Ce 14.0			
		Si/Ni 30.2			

Ce/Zr2		Si/Ce 81.7 Si/Zr 157.1		ZrO(NO ₃) ₂ Ce(NO ₃) ₃	
Co1	Ce	Si/Co 4.0	Co ₃ O ₄	Wetness impregnation Ce(NO ₃) ₃	20
Co2	Co	–	Co ₃ O ₄	Wetness impregnation Co(NO ₃) ₂	28
Co3		–			
Co4		–			
Co5	Co	Si/Co 45.7	Co ₃ O ₄	Co(NO ₃) ₂	29
Co6		Si/Co 26.3			
Co7		Si/Co 17.9			
Co8		Si/Co 26.3			
Co9		Si/Co 17.9			
Co10	Co	Si/Co 18.6	Co ₃ O ₄	Wetness impregnation CoCl ₂	30
Co11		Si/Co 18.6		Wetness impregnation Co(CH ₃ COO) ₂	
Co12		Si/Co 18.6	Co ₃ O ₄ Co ₂ O ₃ CoO	Wetness impregnation Co(NO ₃) ₂	
Co13	Co	Si/Co 13.4	Co ₃ O ₄	Co(NO ₃) ₂	31
Co14	Co	Si/Co 7.2	Co ₃ O ₄	Wetness impregnation Co(NO ₃) ₂	32
Co15	Co	Si/Co 9.1		Wetness impregnation Co(NO ₃) ₂	33

Co16	Co	Si/Co 7.2	Co ₃ O ₄	Wetness impregnation Co(NO ₃) ₂	34
Co17	Co	Si/Co 8.8	Cobalt silicate hydroxide	Deposition- precipitation Co(NO ₃) ₃ urea	35
Co18	Co	Si/Co 8.8	Co ₃ O ₄	Wetness impregnation Co(NO ₃) ₂	36
Co/Al1	Co Al	Si/Co 5.0 Si/Al 4.5		Hydrothermal active γ -Al ₂ O ₃ ground to 1 mm with a ball grinder wetness impregnation Co(NO ₃) ₂	15
Co/Ca1	Co Ca	Si/Co 12.5 Si/Ca 9.0	Co ₃ O ₄	Wetness impregnation Co(NO ₃) ₂ Ca(NO ₃) ₂	31
Co/Ce1	Co Ce	Si/Co 4.0 Si/Ce 32.2	CeO ₂ Co ₃ O ₄	hydrothermal Ce(NO ₃) ₃ Wetness impregnation Co(NO ₃) ₂	20
Co/Ce2	Co Ce	Si/Ce 6.3 Si/Co 2.7	CeO ₂ Co ₃ O ₄	Wetness impregnation Ce(NO ₃) ₃ Co(NO ₃) ₂	22
Co/Ce3		Si/Ce 12.4 Si/Co 3.2			
Co/Ce4		Si/Ce 25.8 Si/Co 3.5			
Co/Ce5		Si/Ce 25.8			

		Si/Co 3.5				
Co/Ce6		Si/Ce 27.6				
		Si/Co 5.0				
Co/Ce7		Si/Ce 29.4				
		Si/Co 8.0				
Co/Mg 1	Co Mg	Si/Co 13.1 Si/Mg 6.9	Co ₃ O ₄	Wetness impregnation Co(NO ₃) ₂ Mg(NO ₃) ₂	31	
Co/Mo 1	Co Mo	Si/Co 76.9 Si/Mo 36.9	β -CoMoO ₄	Wetness impregnation $(\text{NH}_4)_6\text{Mo}_7\text{O}_{24}$ Co(NO ₃) ₂	37	
Co/Mo 2		Si/Co 35.3 Si/Mo 17.0				
Co/Mo 3		Si/Co 21.5 Si/Mo 10.3				
Co/Mo 4		Si/Co 76.9 Si/Mo 36.9		Wetness impregnation $(\text{NH}_4)_6\text{Mo}_7\text{O}_{24}$ Co(NO ₃) ₂ EDTA		
Co/Mo 5		Si/Co 35.3 Si/Mo 17.0				
Co/Mo 6		Si/Co 21.5 Si/Mo 10.3				
Co/Mo 7		Si/Co 76.9 Si/Mo 36.9		Wetness impregnation $(\text{NH}_4)_6\text{Mo}_7\text{O}_{24}$ Co(NO ₃) ₂ citric acid		
Co/Mo 8		Si/Co 35.3 Si/Mo 17.0				
Co/Mo 9		Si/Co 21.5 Si/Mo 10.3				
Co/Ni1	Co Ni	Si/Co 17.7 Si/Ni 17.6	NiO CoCo ₂ O ₄ NiCo ₂ O ₄	Wetness impregnation Co(NO ₃) ₂ Ni(NO ₃) ₂	38	

Co/Ni2	Co Ni Mg	Si/Co 16.7 Si/Ni 16.6 Si/Mg 6.9		Wetness impregnation $\text{Co}(\text{NO}_3)_2$ $\text{Ni}(\text{NO}_3)_2$ $\text{Mg}(\text{NO}_3)_2$	
Co/Ni3	Co Ni La	Si/Co 16.7 Si/Ni 16.6 Si/La 39.3		Wetness impregnation $\text{Co}(\text{NO}_3)_2$ $\text{Ni}(\text{NO}_3)_2$ $\text{La}(\text{NO}_3)_3$	
Co/Ni4	Co Ni Sc	Si/Co 16.7 Si/Ni 16.6 Si/Sc 12.7	NiO CoCo_2O_4 NiCo_2O_4	Wetness impregnation $\text{Co}(\text{NO}_3)_2$ $\text{Ni}(\text{NO}_3)_2$ $\text{Sc}(\text{NO}_3)_3$	
Co/Ru1	Co Ru	Si/Co 7.1 Si/Ru 195.7	Co_3O_4 RuO_2	Wetness impregnation $\text{Co}(\text{NO}_3)_2$ $\text{Ru}(\text{NO})(\text{NO}_3)_3$	32
Co/Ru2		Si/Co 7.1 Si/Ru 129.9			
Co/Ru3		Si/Co 7.1 Si/Ru 97.0			
Cr1	Cr	Si/Cr 15.8		$\text{Cr}(\text{NO}_3)_3$	29
Cu1	Cu	Si/Cu 16.6	CuO After reaction Cu_2O Cu	Wetness impregnation $\text{Cu}(\text{NO}_3)_2$	23
Cu2	Cu	Si/Cu 25.2	CuO	Wetness impregnation $\text{Cu}(\text{NO}_3)_2$	39
Cu3		Si/Cu 11.1	CuO		
Cu4		Si/Cu 9.4	Cu_2O		
Cu5	Cu	Si/Cu 19.3		$\text{Cu}(\text{NO}_3)_2$	29

Cu/Al1	Cu Al	-		One-pot method precipitation condensation $\text{Al}_2(\text{SO}_4)_3$ CuSO_4 ammonia sodium citrate	14
Cu/Ce1	Cu Ce	Si/Cu 24.8 Si/Ce 109.6	CuO CeO_2	Wetness impregnation $\text{Cu}(\text{NO}_3)_2$ $\text{Ce}(\text{NO}_3)_3$	23
Cu/Ce2		Si/Cu 33.1 Si/Ce 73.1			
Cu/Ce3		Si/Cu 49.7 Si/Ce 54.8			
Cu/Ce4	Cu Ce	Si/Cu 60.2 Si/Ce 28.7	CeO_2 No evidence of Cu compounds	Wetness impregnation $\text{Ce}(\text{NO}_3)_3$ $\text{Cu}(\text{NO}_3)_2$	26
Cu/Ce5		Si/Cu 66.7 Si/Ce 81.7 Si/Zr 119.7			
Cu/Ce6	Cu Ce Zr	Si/Cu 70.3 Si/Ce 44.3 Si/Zr 201.7			
Cu/Ni1		Si/Cu 19.4 Si/Ni 83.3			
Cu/Ni2		Si/Cu 23.3 Si/Ni 102.9			
Cu/Ni3		Si/Cu 22.2 Si/Ni 102.7		Precipitation with Na_2CO_3 $\text{Cu}(\text{NO}_3)_2$ $\text{Ni}(\text{NO}_3)_2$	40

Cu/Ni4		Si/Cu 20.3 Si/Ni 83.5		Precipitation with urea Cu(NO ₃) ₂ Ni(NO ₃) ₂	
Cu/Zn1	Cu Zn Al	-		One-pot method precipitation condensation Al ₂ (SO ₄) ₃ CuSO ₄ zinc acetate ammonia sodium citrate	14
Cu/Zr1	Cu Zr	Si/Cu 63.5 Si/Zr 60.7		Wetness impregnation ZrO(NO ₃) ₂ Cu(NO ₃) ₂	26
Fe1	Fe	Si/Fe 6.7	Fe ₃ O ₄	Wetness impregnation Fe(NO ₃) ₃ methanol	41
Fe2		Si/Fe 6.7			
Fe3		Si/Fe 6.7			
Fe4		Si/Fe 6.7		hydrothermal Fe(NO ₃) ₃	
Fe5	Fe	Si/Fe 16.9		Fe(NO ₃) ₃	29
Fe/Al1	Fe Al	Si/Fe 4.8 Si/Al 4.5		Hydrothermal active γ-Al ₂ O ₃ ground to 1 mm with a ball grinder wetness impregnation Fe(NO ₃) ₃	15
Ga1	Ga	Si/Ga 20.0	Ga ₂ O ₃	Ga(NO ₃) ₃	16

K/Mo1	K Mo			Wetness impregnation K_2CO_3 $(NH_4)_6Mo_7O_{24}$	42
K/Mo2					
K/Mo3			K_2MoO_4		
K/Mo4					
La/Ni1	La Ni	Si/La 6.5 Si/Ni 6.5	LaNiO ₃	La(NO ₃) ₃ Ni(NO ₃) ₂ ethanol citric acid	43
La/Ni2	La Ca Ni	Si/La 8.5 Si/Ni 6.8 Si/Ca 34.0	LaNiO ₃ La ₂ O ₃ NiO Perovskite-type oxide	La(NO ₃) ₃ Ni(NO ₃) ₂ Ca(NO ₃) ₂ ethanol citric acid	
La/Ni3	La Ca Ni Co	Si/La 6.9 Si/Ni 5.6 Si/Ca 27.8 Si/Co 5.6	La(NO ₃) ₃ Ca(NO ₃) ₂ Ni(NO ₃) ₂ Co(NO ₃) ₂ ethanol citric acid		
La/Ni4	La Ni	Si/La 34.0 Si/Ni 34.0	LaNiO ₃ perovskite	Wetness impregnation La(NO ₃) ₃ Ni(NO ₃) ₂ citric acid	44
Mg1	Mg	Si/Mg 6.3		Wetness impregnation Mg(NO ₃) ₂	17
Mn1	Mn	Si/Mn 16.7		MnCl ₂	29
Ni1	Ni	Si/Ni 13.3	NiO	Wetness impregnation Ni(NO ₃) ₂ polyethylenimine	45

Ni2	Ni	Si/Ni 10.2	NiO	Wetness impregnation $\text{Ni}(\text{NO}_3)_2$	46
Ni3		Si/Ni 9.2		Mixed suspension with urea $\text{Ni}(\text{NO}_3)_2$	
Ni4		Si/Ni 11.2		Mixed suspension with urea and ascorbic acid $\text{Ni}(\text{NO}_3)_2$	
Ni5	Ni	Si/Ni 19.4		Wetness impregnation $\text{Ni}(\text{NO}_3)_2$	47
Ni6	Ni	Si/Ni 17.9		$\text{Ni}(\text{NO}_3)_2$	29
Ni7	Ni	Si/Ni 7.2	NiO Ni	Wetness impregnation $\text{Ni}(\text{NO}_3)_2$	24
Ni8	Ni	Si/Ni 8.8	NiO	Solvent impregnation $\text{Ni}(\text{NO}_3)_2$	48
Ni9	Ni	Si/Ni 13.4	NiO	Wetness impregnation $\text{Ni}(\text{NO}_3)_2$	17, 31
Ni10	Ni	Si/Ni 18.6	NiO	Wetness impregnation $\text{Ni}(\text{NO}_3)_2$	49
Ni11		Si/Ni 8.8			
Ni12		Si/Ni 5.5			
Ni13		Si/Ni 3.9			
Ni14		Si/Ni 2.9			
Ni15	Ni	Si/Ni 18.6	NiO	Wetness impregnation $\text{Ni}(\text{NO}_3)_2$	50
Ni16		Si/Ni 18.6			
Ni17		Si/Ni 18.6			
Ni18	Ni	Si/Ni 8.8	NiO	Wetness impregnation	51

				Ni(NO ₃) ₂	
Ni19	Ni	Si/Ni 9.2		Wetness impregnation Ni(NO ₃) ₂	33
Ni20	Ni	Si/Ni 56.7	NiO	Wetness impregnation Ni(NO ₃) ₂ pH adjusting method NaOH	52
Ni21		Si/Ni 17.2			
Ni22		Si/Ni 10.7			
Ni23		Si/Ni 9.0			
Ni24	Ni	Si/Ni 18.6	Ni	Wetness impregnation Ni(NO ₃) ₂	25
Ni25	Ni	Si/Ni 7.3	NiO	Wetness impregnation Ni(NO ₃) ₂	53
Ni29	Ni	Si/Ni 19.5	NiO	Wetness impregnation Ni(NO ₃) ₂	54
Ni30		Si/Ni 19.3			
Ni31		Si/Ni 22.2			
Ni32		Si/Ni 20.4			
Ni33		Si/Ni 21.6			
Ni34		Si/Ni 22.2			
Ni35	Ni	Si/Ni 16.9	NiO	Ni(NO ₃) ₂ <i>α-cyclodextrin</i>	55
Ni36		Si/Ni 19.5		Ni(NO ₃) ₂ <i>γ-cyclodextrin</i>	
Ni37	Ni	Si/Ni 12.1	NiO	Wetness impregnation Ni(NO ₃) ₂ ethylenediamine	56

Ni38	Ni	Si/Ni 12.1	NiO	Wetness impregnation $\text{Ni}(\text{NO}_3)_2$ citric acid		
Ni39		Si/Ni 12.1		Wetness impregnation $\text{Ni}(\text{NO}_3)_2$ acetic acid		
Ni40		Si/Ni 12.1		Wetness impregnation $\text{Ni}(\text{NO}_3)_2$		
Ni41	Ni	Si/Ni 89.0	NiO	Wetness impregnation $\text{Ni}(\text{NO}_3)_2$	57	
Ni42		Si/Ni 30.2				
Ni43		Si/Ni 18.3				
Ni44		Si/Ni 9.0				
Ni45		Si/Ni 3.9				
Ni46		Si/Ni 100.1		Wetness impregnation $\text{Ni}(\text{NO}_3)_2$ EDTA		
Ni47		Si/Ni 31.2				
Ni48		Si/Ni 19.4				
Ni49		Si/Ni 9.1				
Ni50		Si/Ni 3.9	NiO			
Ni51	Ni	Si/Ni 19.5	NiO Ni	Wetness impregnation $\text{Ni}(\text{NO}_3)_2$	58	
Ni52		Si/Ni 19.5		Wetness impregnation $\text{Ni}(\text{NO}_3)_2$ Poly(N-vinyl-2-pyrrolidone) (PVP)		
Ni53		Si/Ni 19.5				
Ni54		Si/Ni 19.5				
Ni55		Si/Ni 19.5				
Ni56		Si/Ni 19.5				
Ni57	Ni	Si/Ni 31.7	NiO		59	

Ni58		Si/Ni 20.8		Wetness impregnation nickel citrate	
Ni59		Si/Ni 15.4			
Ni60		Si/Ni 12.1			
Ni61		Si/Ni 9.9			
Ni62	Ni	Si/Ni 33.9	Ni	surfactant-assisted iso-volumetric impregnation method $\text{Ni}(\text{NO}_3)_3$ cetyltrimethylammonium bromide (CTAB)	27
Ni63	Ni	Si/Ni 15.7	NiO	Incipient wetness $\text{Ni}(\text{NO}_3)_2$	60
Ni64		Si/Ni 17.8		Solid-state grinding $\text{Ni}(\text{NO}_3)_2$	
Ni65	Ni	Si/Ni 8.8	Nickel silicate hydroxide	Deposition-precipitation $\text{Ni}(\text{NO}_3)_2$ urea	35
Ni66	Ni	Si/Ni 18.6	Ni	Wet impregnation $\text{Ni}(\text{NO}_3)_2$	61
Ni/Al1	Ni Al	Si/Ni 5.0 Si/Al 4.5	NiO	Hydrothermal active $\gamma\text{-Al}_2\text{O}_3$ ground to 1 mm with a ball grinder wetness impregnation $\text{Ni}(\text{NO}_3)_2$	15
Ni/Ca1	Ni Ca	Si/Ni 13.1 Si/Ca 8.9	NiO	Wetness impregnation $\text{Ni}(\text{NO}_3)_2$ $\text{Ca}(\text{NO}_3)_2$	17, 31
Ni/Ce1	Ni	Si/Ni 7.2	NiO	Hydrothermal	24

	Ce	Si/Ce 52.6	Ni	Ce(NO ₃) ₃	
Ni/Ce2		Si/Ce 26.3 Si/Ni 7.2		Wetness impregnation Ni(NO ₃) ₂	
Ni/Ce3		Si/Ce 18.2 Si/Ni 7.2			
Ni/Ce4	Ni Ce	Si/Ce 13.2 Si/Ni 7.2			
Ni/Ce5		Si/Ni 17.4 Si/Ce 34.6		Solvent impregnation Ni(NO ₃) ₂ Ce(NO ₃) ₂	62
Ni/Ce6	Ni Ce	Si/Ni 17.4 Si/Ce 34.6		Solvent impregnation Ni(NO ₃) ₂ Ce(NO ₃) ₂	
Ni/Ce7		Si/Ce 1000.0 Si/Ni 18.6	Ni	Colloidal acidic suspension of CeO ₂ nanoparticles (10% in water) Wetness impregnation Ni(NO ₃) ₂	25
Ni/Ce8	Ni Ce	Si/Ni 7.1 Si/Ce 73.6	NiO CeO ₂	Wetness impregnation Ni(NO ₃) ₂ Ce(NO ₃) ₃	53
Ni/Ce10	Ni Ce Zr	Si/Ni 7.0 Si/Ce 136.4 Si/Zr 102.9	NiO	Wetness impregnation Ni(NO ₃) ₂ Ce(NO ₃) ₃ Zr(NO ₃) ₄	
Ni/Ce11	Ni Ce	Si/Ni 17.4 Ce/Si 34.6	NiO CeO ₂	wet impregnation Ni(NO ₃) ₂	63

				Ce(NO ₃) ₂	
Ni/Ce1 2		Si/Ni 17.4 Ce/Si 34.6		ultrasonic-assisted impregnation Ni(NO ₃) ₂ Ce(NO ₃) ₂	
Ni/Ce1 3				reflux followed with impregnation Ni(NO ₃) ₂ Ce(NO ₃) ₂	
Ni/Co1	Ni Co	Si/Ni 9.9 Si/Co 80.3		Wetness co- impregnation Ni(NO ₃) ₂	33
Ni/Co2		Si/Ni 11.5 Si/Co 44.3		Co(NO ₃) ₂	
Ni/Co3		Si/Ni 16.1 Si/Co 22.8			
Ni/Co4		Si/Ni 19.2 Si/Co 18.5			
Ni/Co5		Si/Ni 31.4 Si/Co 12.4			
Ni/Co6	Ni Co Al	Si/Co 25.3 Si/Ni 6.3 Si/Al 4.5		Hydrothermal active γ -Al ₂ O ₃ ground to 1 mm with a ball grinder wetness impregnation Co(NO ₃) ₂ Ni(NO ₃) ₂	15
Ni/Co7	Ni Co	Si/Ni 17.6 Si/Co 17.6	Nickel silicate hydroxide Cobalt silicate hydroxide	Deposition- precipitation Ni(NO ₃) ₂ Co(NO ₃) ₃ urea	35

Ni/Fe1	Fe Ni Al			Hydrothermal active γ -Al ₂ O ₃ ground to 1 mm with a ball grinder wetness impregnation Fe(NO ₃) ₃ Ni(NO ₃) ₂	15		
Ni/Mg1	Ni Mg Al	-	NiO-MgO Ni After reaction Ni NiO-MgO Mg ₂ SiO ₄ MgAl ₂ O ₄	Ni(NO ₃) ₂ Mg ₆ Al ₂ (CO ₃)(OH) ₁₆ (hydrotalcite)	64		
Ni/Mg2							
Ni/Mg3							
Ni/Mg4							
Ni/Mg5							
Ni/Mg6	Ni Mg	Si/Ni 12.8 Si/Mg 5.8	NiO	Wetness impregnation Ni(NO ₃) ₂ Mg(NO ₃) ₂	17, 31		
Ni/Sm1	Ni Sm	Si/Ni 8.7 Si/Sm 448.0	NiO	Wetness impregnation Ni(NO ₃) ₂ Sm(NO ₃) ₃	51		
Ni/Sm2		Si/Ni 8.7 Si/Sm 147.6	NiO Sm ₂ O ₃				
Ni/Sm3		Si/Ni 8.5 Si/Sm 72.6					
Ni/Sn1	Ni Sn Al		Ni ₃ Sn ₂ (alloy)	Hydrothermal active γ -Al ₂ O ₃ ground to 1 mm with a ball grinder wetness impregnation SnCl ₂	15		
		Si/Sn 50.9 Si/Ni 6.3 Si/Al 4.5					

				Ni(NO ₃) ₂	
Ni/W1	Ni W	Si/Ni 8.8 Si/W 2.8		Wet impregnation Ni(NO ₃) ₂ (NH ₄) ₆ H ₂ W ₁₂ O ₄₀	61
Ni/W2	Ni W Zr	Si/Ni 11.2 Si/W 17.6 Si/Zr 3.2	WO ₂ Ni ₄ W (alloy) W	Hydrothermal ZrO(NO ₃) ₂ Wet impregnation Ni(NO ₃) ₂ (NH ₄) ₆ H ₂ W ₁₂ O ₄₀	
Ni/W3		Si/Ni 7.3 Si/W 3.8 Si/Zr 2.1			
Ni/W4		Si/Ni 3.4 Si/W 1.1 Si/Zr 1.0			
Ni/Y1	Ni Y	Si/Y 55.5 Si/Ni 8.5	NiO	Solvent impregnation Ni(NO ₃) ₂ Y(NO ₃) ₃	48
Ni/Zr1	Ni Zr	Si/Ni 8.5 Si/Zr 59.5	NiO	Solvent impregnation Ni(NO ₃) ₂ Zr(NO ₃) ₄	
Ni/Zr2	Ni Zr	Si/Ni 7.2 Si/Ce 81.4	NiO ZrO ₂	Wetness impregnation Ni(NO ₃) ₂ Zr(NO ₃) ₄	53
Ni/Zr3	Ni Zr	Si/Ni 13.2 Si/Zr 3.7	Ni	Hydrothermal ZrO(NO ₃) ₂ Wet impregnation Ni(NO ₃) ₂	61
Sm/Co1	Sm Co	Si/Sm 519.5 Si/Co 8.8	Co ₃ O ₄	Wetness impregnation	36

Sm/Co2		Si/Sm 258.3 Si/Co 8.7		Co(NO ₃) ₂ Sm(NO ₃) ₃	
Sm/Co3		Si/Sm 171.2 Si/Co 8.7			
Sm/Ni1	Sm Ni	Si/Sm 519.5 Si/Ni 8.7	NiO	Wetness impregnation Ni(NO ₃) ₂ Sm(NO ₃) ₃	36
Sm/Ni2		Si/Sm 258.3 Si/Ni 8.7			
Sm/Ni3		Si/Sm 171.2 Si/Ni 8.6			
Sm/Ni4	Sm Ni	Si/Sm 84.2 Si/Ni 8.5	NiO	Solvent impregnation Ni(NO ₃) ₂ Sm(NO ₃) ₃	48
Sn/Al1	Sn Al	Si/Sn 10.2 Si/Al 4.5	SnO	Hydrothermal active γ -Al ₂ O ₃ ground to 1 mm with a ball grinder wetness impregnation SnCl ₂	15
Ti1	Ti	Si/Ti 5.1	No crystalline Ti compounds	chemical vapor deposition TiCl ₄ hydrolysis	13
Ti2		Si/Ti 22.7			
Ti3		Si/Ti 2.8			
Ti4		Si/Ti 9.1			
Ti5		Si/Ti 26.2			
Ti6		Si/Ti 1.7			
Ti7		Si/Ti 1.7			
Ti8		Si/Ti 3.7			
Ti9		Si/Ti 3.3			
Ti10		Si/Ti 2.9			

Ti11		Si/Ti 2.9			
Ti12		Si/Ti 2.0			
Ti13		Si/Ti 1.8			
Ti/Al1	Ti Al	Si/Ti 15.5	No crystalline Ti or Al compounds	chemical vapor deposition TiCl ₄ AlCl ₃ hydrolysis	
Ti/Al2		Si/Al 47.1			
Ti/Al3		Si/Ti 19.5			
		Si/Al 77.1			
Ti/Al4		Si/Ti 6.3			
	V	Si/Al 77.1			
V1		Si/V 22.7	VO _x	Wet impregnation Vanadium oxo-complexes	65
V2		Si/V 8.6			
V3	V	Si/V 12.0	V ₂ O ₅	Wetness impregnation NH ₄ NO ₃	66
V4		Si/V 10.6			
V5		Si/V 8.7			
V6		Si/V 7.5			
V7		Si/V 6.9			
Zn1	Zn	Si/Zr 19.8		Zn(NO ₃) ₃	29
Zn2	Zn	Si/Zn 10882.2	ZnO	chemical vapor deposition Zn (metal)	19
Zn3		Si/Zn 518.2			
Zn4		Si/Zn 236.6			
Zn5		Si/Zn 28.3			
Zn6		Si/Zn 24.8			
Zn7		Si/Zn 63.3			
Zn8		Si/Zn 19.4			
Zn9		Si/Zn 15.8			
Zn10		Si/Zn 15.8			
Zn11		Si/Zn 26.7			

Zn12		Si/Zn 39.4			
Zn/Al1	Zn Al			One-pot method precipitation condensation $\text{Al}_2(\text{SO}_4)_3$ zinc acetate ammonia sodium citrate	14
Zr1	Zr	Si/Zr 11.1	Zirconium phosphate	Zirconium(IV) n-propoxide	67
Zr2	Zr	Si/Zr 40.7		Wetness impregnation $\text{ZrO}(\text{NO}_3)_2$	26
Zr3	Zr	Zr/Si 4.0		Hydrothermal $\text{ZrO}(\text{NO}_3)_2$	61
Zr/Ce1	Zr Ce Ni	Si/Zr 5.0 Si/Ce 3.3 Si/Ni 8.8	$\text{Ce}_{0.75}\text{Zr}_{0.25}\text{O}_2$ NiO	Wetness impregnation $\text{ZrO}(\text{NO}_3)_2$ $\text{Ce}(\text{NO}_3)_3$	68
Zr/Ce2		Si/Zr 5.0 Si/Ce 3.3 Si/Ni 8.8	NiO	$\text{Ni}(\text{NO}_3)_2$	
Zr/Ce3		Si/Zr 5.0 Si/Ce 3.3 Si/Ni 8.8		Wetness impregnation $\text{ZrO}(\text{NO}_3)_2$ $\text{Ce}(\text{NO}_3)_3$ $\text{Ni}(\text{NO}_3)_2$ ammonia	
Zr/P1	Zr P	Si/Zr 11.5 Si/P 6.2	Zirconium phosphate	Zirconium(IV) n-propoxide POCl_3	67
Zr/P2		Si/Zr 5.2 Si/P 3.1			
Zr/P3		Si/Zr 9.2		One-pot grafting	

Zr/P4		Si/P 4.3 Si/Zr 7.2 Si/P 3.4		Zirconium(IV) n-propoxide POCl ₃	
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Table S2. Characterization of SBA-15 and of SBA-15-metal composites. SSA in m²/g.

Metal/Code	SSA original SBA-15	SSA composite	XRD, structure, size of crystallites	Other methods	Reference
Al1	656 766 816 826 792 1103 904 873	656 766 816 826 792 1103 904 873	No crystalline Al compounds	TEM ²⁹ Si MAS-NMR NH ₃ -TPD FTIR	12
Al2					
Al3					
Al4					
Al5					
Al6					
Al7					
Al8					
Al9	910	881	No crystalline Al compounds	TEM ζ potential	13
Al10		884			
Al11		889			
Al12		878			
Al13		915			
Al14		864			
Al15		623	No crystalline Al compounds	HRTEM TG DTG FTIR	14
Al16		830			
Al17		890			
Al18	934	449			15

Al19		538	No crystalline Al compounds		
Al20		536			
Al21	1050	920	No crystalline Al compounds	²⁷ Al-MAS-NMR TEM	16
Al/Ti1	910	826		TEM	13
Al/Ti2		807		ζ potential	
Ca1	581	333		TEM H ₂ -TPR TGA	17
Ca2	536	408		CO ₂ -TPR	18
Ca3		342		TEM	
Ca4		282		TGA	
Ca5		172		DTG	
Ca6		152		DSC	
Ca7		169			
Cd1	895	928	CdO, monteponite	TEM	19
Cd2		784		ζ potential	
Cd3		856			
Cd4		821			
Cd5		888			
Cd6		928			
Cd7		833			
Cd8		816			
Cd9		849			
Cd10		852			
Cd11		862			
Ce1	672	912	CeO ₂ , cubic		20
Ce2	812	629	CeO ₂	TEM	21
Ce3	662	797			22
Ce4		864			

Ce5		912		UV-vis	
Ce6	807	703	CeO ₂ , 3.0 nm	Raman XPS FTIR UV-Vis TPR-TG TPR-DTG	23
Ce7	941	913		TEM	24
Ce8		885		TEM	
Ce9		512		XPS	
Ce10		509		TEM	
Ce11	739	896	-	Raman UV-vis	25
Ce12		876	CeO ₂ , cubic, 11 nm		
Ce13		782	CeO ₂ , cubic, 20 nm		
Ce14		696	CeO ₂ , cubic, 25 nm		
Ce15	720	542	CeO ₂ , 12.6 nm	UV-vis XPS FTIR	26
Ce/Ni11	687	600	Ni	TEM H ₂ -TPR EELS TPO TGA DTA	27
Ce/Ni12		540			
Ce/Ni13		538	CeO ₂		
Ce/Ni14		514			
Ce/Zr1	720	537	CeO ₂ , 7.9 nm	UV-vis XPS	26

				FTIR TEM	
Ce/Zr2		550	CeO ₂ , 14.0 nm	UV-vis XPS FTIR	
Co1	672	478	Co ₃ O ₄ , spinel, 7.6 nm	H ₂ -TPR	20
Co2				TEM	28
Co3				SEM	
Co4				XRF TPO	
Co5	608	511			29
Co6		490		HRTEM	
Co7		468			
Co8		292			
Co9		506	Co ₃ O ₄		
Co10			Co ₃ O ₄ , 14 nm	SEM TEM FTIR	30
Co11				FTIR	
Co12					
Co13		539	Co ₃ O ₄ , cubic spinel, 9.4 nm	TEM H ₂ -TPR	31
Co14	699	589	Co ₃ O ₄ , 7 nm	TEM H ₂ -TPR EDS	32
Co15	775	283		FFT TGA	33

				HRTEM H ₂ -TPR DRM XPS	
Co16	803	639	Co ₃ O ₄ , cubic, 8.6 nm	TEM HRTEM EDXS H ₂ -TPR	34
Co17	738	280	Cobalt silicate hydroxide	TEM XANES H ₂ -TPR XPS	35
Co18	781	628	Co ₃ O ₄ , 11.5 nm	SEM	36
Co/Al1				TGA	15
Co/Ca1		283		TEM H ₂ -TPR	31
Co/Ce1	672	529	Co ₃ O ₄ , spinel, 10.6 nm CeO ₂ , cubic	H ₂ -TPR	20
Co/Ce2	662	452	CeO ₂ , cubic Co ₃ O ₄ , spinel, 10.9 nm		22
Co/Ce3		496	CeO ₂ , cubic Co ₃ O ₄ , spinel, 10.7 nm		
Co/Ce4		530	CeO ₂ , cubic Co ₃ O ₄ , spinel, 10.6 nm	UV-vis	
Co/Ce5		556	CeO ₂ , cubic		

			Co_3O_4 , spinel, 6.2 nm		
Co/Ce6		584	CeO_2 , cubic Co_3O_4 , spinel, 2.3 nm	UV-vis	
Co/Ce7		418			
Co/Mg1		333	Co_3O_4 , cubic spinel, 6.6 nm	TEM H ₂ -TPR	31
Co/Mo1	775	662	$\beta\text{-CoMoO}_4$	HRTEM H ₂ -TPR UV-vis	37
Co/Mo2		581			
Co/Mo3		551			
Co/Mo4		529			
Co/Mo5		483			
Co/Mo6		442			
Co/Mo7		543			
Co/Mo8		471			
Co/Mo9		435			
Co/Ni1	819	469	CoCo_2O_4 , spinel	EDX H ₂ -TPR CO ₂ -TPR TEM TGA DTA	38
Co/Ni2		426			
Co/Ni3		584			
Co/Ni4		528			
Co/Ru1	699	629	Co_3O_4 , 10.5 nm RuO_2 , 16.6 nm	TEM EDS	32
Co/Ru2		425	Co_3O_4 , 9.5 nm RuO_2 , 40.5 nm	TEM TPO H ₂ -TPR EDS	

Co/Ru3		472	Co ₃ O ₄ RuO ₂ , 13.2 nm	TEM EDS	
Cu1	807	678	CuO, 43.8 nm	Raman XPS FTIR UV-Vis TPR-TG TPR-DTG	23
Cu2	574	355	CuO	H ₂ -TPR	39
Cu3		320	CuO		
Cu4		368	CuO Cu ₂ O		
Cu/Al1		346		HRTEM TG DTG FTIR	14
Cu/Ce1	807	690	CuO, 49.2 nm	Raman XPS FTIR UV-Vis TPR-TG TPR-DTG	23
Cu/Ce2		692	CuO, 19.1 nm		
Cu/Ce3		626			
Cu/Ce4	720	501	CeO ₂ , 29.0 nm	UV-vis XPS FTIR	26
Cu/Ce5		509	CeO ₂ , 14.0 nm		

				TEM	
Cu/Ce6		504	CeO ₂ , 9.6 nm	UV-vis XPS FTIR	
Cu/Ni1	816	717	NiO, cubic, 29.5 nm, CuO, monoclinic, 14.5 nm	TEM HRTEM H ₂ -TPR XPS	40
Cu/Ni2		699			
Cu/Ni3		458			
Cu/Ni4		323			
Cu/Zn1		423		HRTEM TG DTG FTIR	14
Cu/Zr1	720	497		UV-vis XPS FTIR	26
Fe1				TEM FTIR TGA	41
Fe2					
Fe3					
Fe4					
Fe/Al1					15
Ga1	1050	950	Ga ₂ O ₃	⁷¹ Ga-MAS-NMR TEM	16
K/Mo1				H ₂ -TPR	42
K/Mo2					
K/Mo3			K ₂ MoO ₄		
K/Mo4					

La/Ni1	620	81			43
La/Ni2		65			
La/Ni3		23			
La/Ni4	612	246	LaNiO ₃ , type perovskite	TEM EDX TG DTA H ₂ -TPR	44
Mg1	581	350		TEM H ₂ -TPR TGA	17
Mo1			MoO ₃	H ₂ -TPR	42
Ni1	872	491	NiO, 3.3 nm	TEM Raman TGA FTIR	45
Ni2	884	639	NiO, cubic, 12 nm	HRTEM TG H ₂ -TPR	46
Ni3		391	NiO, cubic		
Ni4		306	NiO, cubic		
Ni5	912	556		DRIFFT	47
Ni7			Ni, 10.6 nm	TGA THP H ₂ -TPR	24
Ni8		401	NiO, 10.6 nm	TEM HRTEM	48
Ni9	581	545	NiO, cubic, 14.8 nm	TEM H ₂ -TPR TGA	17, 31
Ni10	675	505	NiO, 94 nm	TEM	49

Ni11		480	NiO, 120 nm	H ₂ -TPR	
Ni12		420	NiO, 123 nm		
Ni13		400	NiO, 271 nm		
Ni14		380	NiO, 310 nm		
Ni15	598	455	NiO, cubic, 5.5 nm	TEM H ₂ -TPR	50
Ni16	646	528	NiO, cubic, 3.3 nm		
Ni17	614	515	NiO, cubic, 5.9 nm		
Ni18	782	401	NiO, 9.8 nm		
Ni19	775	320		FFT TGA HRTEM H ₂ -TPR DRM XPS	33
Ni20	756	620	NiO	SEM TEM EDS H ₂ -TPR	52
Ni21		600			
Ni22		422			
Ni23		476			
Ni24	739	594	Ni, 8.0 nm	Raman UV-vis	25
Ni25	799	582	NiO, cubic, 8.7 nm	H ₂ -TPR XP TEM TG TPO	53

				Raman	
Ni29	790	586	NiO, 13.0 nm	TEM Raman TGA DCS	54
Ni30		586	NiO, 9.3 nm		
Ni31		593			
Ni32		549		TEM Raman TGA DSC XPS	
Ni33		573		TEM Raman TGA DSC	
Ni34		588		TEM Raman TGA DSC XPS	
Ni35	815	534	NiO	TEM H ₂ -TPR TGA	55
Ni36		529			
Ni37	810	511			56
Ni38		579			
Ni39		552			
Ni40		663			
Ni41	913	814	NiO, 8.0 nm	UV-vis	57

Ni42		783	NiO, 10.9 nm	TGA H ₂ -TPR HRTEM	
Ni43		764	NiO, 13.8 nm		
Ni44		733	NiO, 16.7 nm		
Ni45		565	NiO, 18.3 nm		
Ni46		657			
Ni47		589			
Ni48		563			
Ni49		529			
Ni50		411	NiO, 6.0 nm		
Ni51			NiO, 13.0 nm after reaction Ni, 14.3 nm		
Ni52			NiO, 8.9 nm after reaction Ni, 11.5 nm	¹ H NMR TPO TGA-DSC	58
Ni53			NiO, 4.6 nm after reaction Ni, 8.0 nm		
Ni54			NiO, 4.3 nm after reaction Ni, 8.5 nm		
Ni55			NiO, 4.7 nm after reaction Ni, 8.2 nm		
Ni56			NiO, 15.7 nm after reaction Ni, 17.2 nm		
Ni57			NiO	H ₂ -TPR TEM TG	59
Ni58					
Ni59					

Ni60			NiO	DSC	
Ni61					
Ni62	687		Ni	TEM H ₂ -TPR EELS TPO TGA DTA	27
Ni63	682	578	NiO	H ₂ -TPR TEM TG DSC	60
Ni64		551			
Ni65	738		Nickel silicate hydroxide	TEM XANES H ₂ -TPR XPS	35
Ni66	652		Ni	TG DT	61
Ni67	781	401	NiO, 8.95 nm	SEM	36
Ni/Al1			NiO	SEM EDS TG	15
Ni/Ca1	581	291	NiO, cubic, 6.7 nm	TEM H ₂ -TPR	17, 31
Ni/Ce1				TEM THP XPS H ₂ -TPR	24
Ni/Ce2			Ni, 7.2 nm	TEM TGA	

				THP XPS H ₂ -TPR	
Ni/Ce3			Ni, 8.6 nm	TEM TGA THP	
Ni/Ce4				TEM THP H ₂ -TPR	
Ni/Ce5		650	NiO, 14 nm CeO ₂ , 5 nm	TEM H ₂ -TPR	62
Ni/Ce6		607	NiO, 6 nm CeO ₂ , 4 nm		
Ni/Ce7	739	624	Ni, 8.2 nm	H ₂ -TPR	25
Ni/Ce8	799	453	NiO, cubic, 5.6 nm CeO ₂ , cubic	H ₂ -TPR XP TEM TG TPO Raman	53
Ni/Ce10		479	NiO, cubic, 6.4 nm		
Ni/Ce11	856	377	NiO, cubic, 10.2 nm CeO ₂ , 7.6 nm		63
Ni/Ce12			NiO, cubic, 9.5 nm CeO ₂ , 6.9 nm		
Ni/Ce13		414	NiO, cubic, 9.9 nm CeO ₂ , 7.4 nm		
Ni/Co1	775	316		FFT	33

Ni/Co2		294		TGA HRTEM H ₂ -TPR DRM	
Ni/Co3		327		FFT TGA HRTEM H ₂ -TPR DRM XPS	
Ni/Co4		285		FFT	
Ni/Co5		303		TGA HRTEM H ₂ -TPR DRM	
Ni/Co6				TGA	15
Ni/Co7	738		Nickel silicate hydroxide Cobalt silicate hydroxide	TEM XANES H ₂ -TPR XPS	35
		261			
Ni/Mg1			Ni, 14.2 nm NiO-MgO solid solution	H ₂ -TPR TPO TEM	64
Ni/Mg2			Ni, 16.9 nm NiO-MgO solid solution		
Ni/Mg3			Ni, 21.0 nm NiO-MgO solid solution		
Ni/Mg4			Ni, 12.2 nm		

			NiO-MgO solid solution		
Ni/Mg5			Ni, 18.2 nm NiO-MgO solid solution		
Ni/Mg6	581	313	NiO, cubic, 13.8 nm	TEM H ₂ -TPR	17,31
Ni/Sm1	782	663	NiO, 13.8 nm		51
Ni/Sm2		582	NiO, 8.6 nm		
Ni/Sm3		423	NiO, 7.3 nm	XRF TEM SEM H ₂ -TPR TPO	
Ni/Sn1			Ni ₃ Sn ₂ (alloy)	SEM EDS TG	15
Ni/W1	652	148		TG	61
Ni/W2		394	WO ₂ Ni ₄ W (alloy) W	DT	
Ni/W3		211			
Ni/W4		151		TEM/EDX SEM TGA TG DT	
Ni/Y1		434	NiO, 10.5 nm	TEM	48
Ni/Zr1		568	NiO, 11.7 nm	HRTEM	
Ni/Zr2	799	474	NiO, cubic, 5.4 nm	H ₂ -TPR XP TEM	53

			ZrO ₂ , monoclinic	TG TPO Raman	
Ni/Zr3	652	561	Ni	TG DT	61
Sm/Co1	781	652	Co ₃ O ₄ , 11.5 nm		36
Sm/Co2		564	Co ₃ O ₄ , 9.85 nm	TEM HRTEM H ₂ -TPR SEM TGA	
Sm/Co3		740	Co ₃ O ₄ , 13.95 nm		
Sm/Ni4		423	NiO, 9.7 nm	TEM HRTEM	48
Sm/Ni1	781	663	NiO, 9.43 nm		36
Sm/Ni2			NiO, 7.26 nm	TEM HRTEM H ₂ -TPR SEM TGA	
Sm/Ni3		468			
Sm/Ni3		582	NiO, 8.22 nm		
Sn/Al1			SnO	SEM	15
Ti1	910	666	No crystalline Ti compounds	ζ potential TEM	13
Ti2		800			
Ti3		596			
Ti4		751			
Ti5		870			
Ti6		409			
Ti7		476			

Ti8		634			
Ti9		629			
Ti10		595			
Ti11		580			
Ti12		523			
Ti13		471			
Ti/Al1		889	No crystalline Ti or Al compounds		
Ti/Al2		919			
Ti/Al3		679			
Ti/Al4		728			
V1	780	600	UV-vis Raman H ₂ -TPR SEM	65	
V2		300			
V3	793	502	V ₂ O ₅	UV-vis	66
V4		487		H ₂ -TPR	
V5		480		SEM	
V6		468		EDX	
V7		419		Raman	
Zn2		609	ZnO, zincite		19
Zn3		680			
Zn4		680			
Zn5		448			
Zn6		373			
Zn7		726	1109		
Zn8		584			
Zn9		481			
Zn10		323			
Zn11		495			
Zn12		269			

Zn/Al1		488		HRTEM TG DTG FTIR	14
Zr1	742	521		TEM ³¹ P MAS NMR ²⁹ Si MAS NMR NH ₃ -TPD	67
Zr2	720	542		UV-vis XPS FTIR	26
Zr3	652	608		TG DT	61
Zr/Ce1	884	423	NiO, cubic, 11 nm	TEM HRTEM H ₂ -TPR TGA	68
Zr/Ce2		472	NiO, cubic, 9 nm		
Zr/Ce3		489	NiO, cubic		
Zr/P1	742	516	zirconium phosphate	TEM ³¹ P MAS NMR ²⁹ Si MAS NMR NH ₃ -TPD	67
Zr/P2		489			
Zr/P3		400			
Zr/P4		279			